

Data Sheet

July 1999

Radiation Hardened 8K x 8 CMOS PROM

inter_{sil}

Intersil's Satellite Applications Flow[™] (SAF) devices are fully tested and guaranteed to 100kRAD total dose. These QML Class T devices are processed to a standard flow intended to meet the cost and shorter lead-time needs of large volume satellite manufacturers, while maintaining a high level of reliability.

The Intersil HS-6664RH-T is a radiation hardened 64K CMOS PROM, organized in an 8K word by 8-bit format. The chip is manufactured using a radiation hardened CMOS process, and utilizes synchronous circuit design techniques to achieve high speed performance with very low power dissipation.

On-chip address latches are provided, allowing easy interfacing with microprocessors that use a multiplexed address/data bus structure. The output enable control (\overline{G}) simplifies system interfacing by allowing output data bus control in addition to the chip enable control (\overline{E}). All bits are manufactured storing a logical "0" and can be selectively programmed for a logical "1" at any bit location.

Specifications

Specifications for Rad Hard QML devices are controlled by the Defense Supply Center in Columbus (DSCC). The SMD numbers listed below must be used when ordering.

Detailed Electrical Specifications for the HS-666s4RH-T are contained in SMD 5962-95626. For more information, visit our website at: www.intersil.com/

Intersil's Quality Management Plan (QM Plan), listing all Class T screening operations, is also available on our website.

www.intersil.com/

Ordering Information

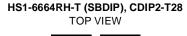
ORDERING INFORMATION	PART NUMBER	TEMP. RANGE (^o C)
5962R9562601TXC	HS1-6664RH-T	-55 to 125
HS1-6664RH/Proto	HS1-6664RH/Proto	-55 to 125
5962R9562601TYC	HS9-6664RH-T	-55 to 125
HS9-6664RH/Proto	HS9-6664RH/Proto	-55 to 125

NOTE: Minimum order quantity for -T is 150 units through distribution, or 450 units direct.

Features

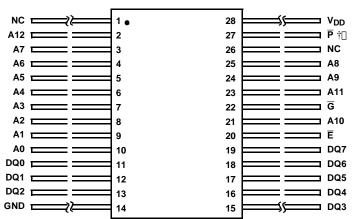
- QML Class T, Per MIL-PRF-38535
- Radiation Performance
 - Gamma Dose (γ) 1 x 10⁵ RAD(Si)
 - No Latch-Up, SEU LET >100MeV/mg/cm²
- Transient Output Upset >5 x 10⁸ RAD (Si)/s
- Fast Access Time 35ns (Typical)
- Single 5V Power Supply, Synchronous Operation
- Single Pulse 10V Field Programmable NiCr Fuses
- · On-Chip Address Latches, Three-State Outputs
- Low Standby Current <500µA (Pre-Rad)
- Low Operating Current <15mA/MHz

Pinouts



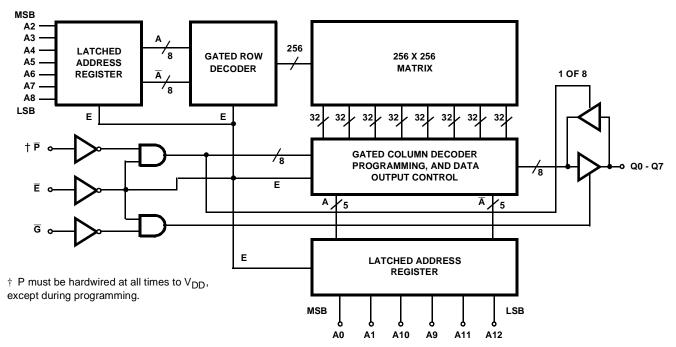
	-		
1 2 3 4 5 6 7 8 9 12 12 12 NC A12 A7 A6 4 5 6 7 8 9 12 12 12 A12 A7 A6 A5 6 1 8 9 12 12 12 A12 A1 A1 A2 A1 A1 12 12 12 A1 A1 A1 A1 A1 12 12 12		26 25 24 23 22 21 20 19 18 17	V _{DD} P † NC A8 A9 A11 G A10 E DQ7 DQ6 DQ5
DQ1 12		17	DQ5
DQ2 13		16	DQ4
GND 14		15	DQ3

HS9-6664RH-T (FLATPACK), CDFP3-F28 TOP VIEW



† P must be hardwired at all times to V_{DD}, except during programming.





Ē	G	MODE
0	0	Enabled
0	1	Output Disabled
1	Х	Disabled

Timing Waveform

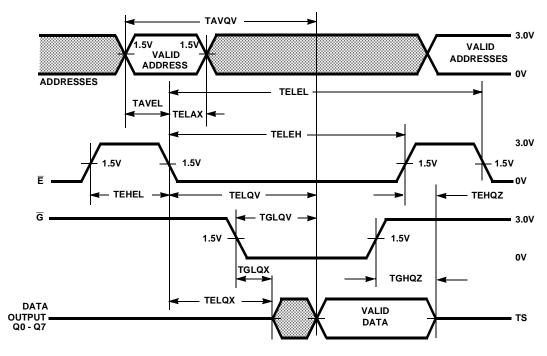


FIGURE 1. READ CYCLE

Die Characteristics

DIE DIMENSIONS:

(6883μm x 7798μm x 483μm ±25.4μm) 271 x 307 x 19mils ±1mil

METALLIZATION:

MI: 6kÅ ±1kÅ Si/Al/Cu 2kÅ ±500Å TiW M2: 10kÅ ±2kÅ Si/Al/Cu

SUBSTRATE POTENTIAL:

 V_{DD}

BACKSIDE FINISH:

Silicon

Metallization Mask Layout

PASSIVATION:

Type: Silox (S_iO₂) Thickness: 8kÅ ±1kÅ

WORST CASE CURRENT DENSITY:

< 2.0e5 A/cm²

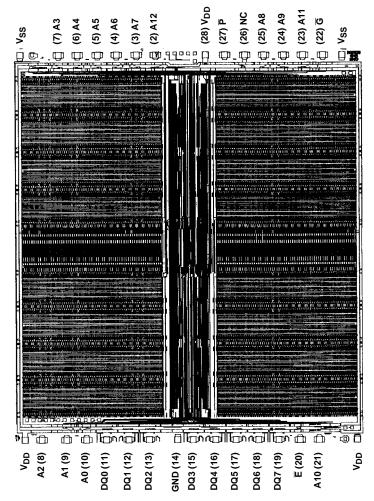
TRANSISTOR COUNT:

110, 874, (27,719 Gates)

PROCESS:

AVLSI

HS-6664RH-T



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